

## Supplementary Information

# Natural Deep Eutectics: Expanding Green Solvents for Thermal-/Photo-Induced Polymerization of *N*- Isopropylacrylamide Toward Key Components for Sustainable Production of Semi-Natural Polymers

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## EXPERIMENTAL SECTION

### 1. Materials

*N*-Isopropylacrylamide (NIPAM, Wako, > 98.0%) was purified by recrystallization from hexane. Thymol (Thy, TCI, >99.0 %), (±)-menthol (Men, TCI, >98.0 %), coumarin (Cou, Wako, >98.0 %), and 1-tetradecanol (Tdc, TCI, >98.0 %) were used without further purification. The melting points, as stated by the supplier, are 49.0–52.0 °C for Thy, 28 °C for Men, 68–72 °C for Cou, 38.0–41.0 °C for Tdc, and 63.0–67.0 °C for NIPAM. 2,2'-Azobis(isobutyronitrile) (AIBN, Kanto Chemical, 97 %) was purified by recrystallization from methanol. 2,2-Dimethoxy-2-phenylacetophenone (DMPA, TCI, >98.0%), 2-cyano-2-propyl dodecyl trithiocarbonate (97%, Sigma Aldrich), and other materials were used without further purification.

### 2. Preparation of natural deep eutectic solvents (NADESs) and polymerization in NADESs

#### 2.1. Preparation of NADESs

NADESs were prepared by simple mixing two solids (e.g., Thy/Men, Thy/Cou, and Tdc/Men) at different feed ratios (1/2, 1/1, and 2/1), according to a reported method.<sup>1</sup> For instance, Thy (1.50g, 10.0 mmol) and Men (1.56 g, 10.0 mmol) were placed in a 10 mL glass vial equipped with a magnetic stirring bar and sealed with a plastic cap. The mixture was stirred under ambient conditions (approximately 25 °C in the air) for 3 h to afford Thy/Men (1/1) as a colorless liquid. The same simple method was used for the preparation of other NADESs. In all cases, mixing was performed under ambient conditions until a homogeneous solution was obtained (approximately 1 h for Thy/Men (1/2), 1.5 h for Tdc/Men (1/2), 2 h for Thy/Cou (1/1), and 1.5 h for Thy/Cou (2/1), respectively). The resulting NADESs were insoluble in water, and displayed a good miscibility in organic solvents, such as diethyl ether (Table S1). These hydrophobic NADESs, which were characterized by proton nuclear magnetic resonance (<sup>1</sup>H NMR) measurement (Figure S1), were used directly for the polymerization.

## 2.2. Thermally-induced polymerization of NIPAM in NADES

A typical procedure for the thermally-induced free radical polymerization is as follows (Run 1 in Table 1): AIBN (1.64 mg, 0.01 mmol) and NIPAM (113 mg, 1.0 mmol) were dissolved in Thy/Men (1/1) NADES (339 mg, [M] = 25 wt. %) in a polymerization ampoule, and the mixture was degassed by three freeze-evacuate-thaw cycles. After sealing the ampoule, polymerization was performed at 60 °C for 24 h. Monomer conversion (>99%) was evaluated using <sup>1</sup>H NMR measurement of the crude product (Figure S3) by comparing the integration of the CH<sub>2</sub>=C- resonance at 5.50 ppm with that of the -CH- main chain peak at 3.80 ppm. The mixture was purified by precipitation in diethyl ether, followed by filtration and then drying in vacuum to give PNIPAM (91.8 mg, yield = 81 %). The resulting PNIPAM was further characterized by <sup>1</sup>H NMR and size-exclusion chromatography (SEC) measurements (Figures S3 and S4).

For the thermally-induced RAFT polymerization (Run 2 in Table S3) using a trithiocarbonate-type chain transfer agent (CTA), AIBN (3.28 mg, 0.02 mmol), 2-cyano-2-propyl dodecyl trithiocarbonate (13.8 mg, 0.04 mmol), and NIPAM (453 mg, 4.0 mmol) were dissolved in Thy/Men (1/1) NADES (1.36 g, [M] = 25 wt. %). Thereafter, polymerization was performed in a sealed glass ampoule using the same procedure as that used for the thermally-induced free radical polymerization.

## 2.3. Photo-induced polymerization of NIPAM in NADES

A typical procedure for the photo-induced free radical polymerization of NIPAM is as follows (Run 3 in Table S7): DMPA (5.13mg, 0.02 mmol), NIPAM (226 mg, 2.0 mmol), and Thy/Men (1/1) NADES (0.528 g, [M] = 30 wt. %) were placed in a 5 mL glass vial. The mixture was stirred under air at room temperature for approximately 30 min with light shielding until a homogeneous solution was obtained. The mixture was irradiated with a mercury UV lamp (365 nm, 6.0 mW/cm<sup>2</sup>, HLR100T-2 with HB100A) for 10 min under ambient conditions. The determination of the monomer conversion (94 %) by <sup>1</sup>H NMR, purification of the crude product by precipitation in diethyl ether (Yield = 77 %, 0.175 g), and characterization of resulting PNIPAM by <sup>1</sup>H NMR and SEC measurements were conducted using the same procedures as those used for the thermally-induced free radical polymerization.

For the photo-induced RAFT polymerization, DMPA (5.13mg, 0.02 mmol), NIPAM (226 mg, 2.0 mmol), and CTA (6.91 mg, 0.02 mmol) were dissolved in Thy/Men (1/1) NADES (0.528 g, [M] = 30 wt. %). Thereafter, polymerization was conducted by photolyzing with a 365 nm wavelength LED–UV light (HLV-24UV365-4WNRBT, CCS Inc., 6 cm away, LED = 330 mW/cm<sup>2</sup>) under ambient conditions.

### 3. Synthesis and polymerization of NIPAM-based natural deep eutectic monomers (NADEMs)

#### 3.1. Synthesis of NIPAM-based natural deep eutectic monomers (NADEMs)

All NADEMs were prepared by simple mixing of NIPAM with natural components (Thy, Men, Cou, and Tdc) under atmospheric conditions. As a representative example of NIPAM/Men (1/1), NIPAM (0.339 g, 3.0 mmol) and Men (0.469 g, 3.0 mmol) were placed in a 10 mL glass vial equipped with a magnetic stirring bar in air. The mixture was stirred on a hot plate at 30 °C for 30 min to afford NIPAM/Men as a colorless liquid.

#### 3.2 Photo-induced polymerization of NIPAM-based NADEMs

The resulting NIPAM/Men (1/1) NADEM was used directly for the photo-induced polymerization. To the NIPAM/Men (1/1) NADEM (790 mg, 3.0 mmol) in the glass vial, DMPA (7.7 mg, 0.03 mmol) was added, and the mixture was stirred under air at room temperature for approximately 5 min with light shielding until a homogeneous solution was obtained. After the magnetic stirring bar was removed, photo-induced radical polymerization was conducted by photolyzing with a 365 nm wavelength LED–UV light (HLV-24UV365-4WNRBT, CCS Inc., 10 cm away, LED = 130 mW/cm<sup>2</sup>) under ambient conditions. After the polymerization, the mixture was dissolved in a small amount of methanol, and purified by precipitation in diethyl ether, followed by filtration and drying under vacuum to give PNIPAM (270 g, yield = 79 %).

The same procedures were used for the preparation of other NADEMs and subsequent photo-induced polymerization. When the NADEM was prepared at higher polymerization temperatures (e.g., 50 °C for the preparation for NIPAM/Tdc (1/1)) NADEM was prepared by heating and stirring two solids using a

hot plate, and used directly for the photopolymerization. The  $^1\text{H}$  NMR and digital photographs of the NIPAM-based NADEMs and corresponding NADEM-based polymers are shown in Table 2 and Figures S16-S19 (Supporting Information).

### 3. Instrumentation

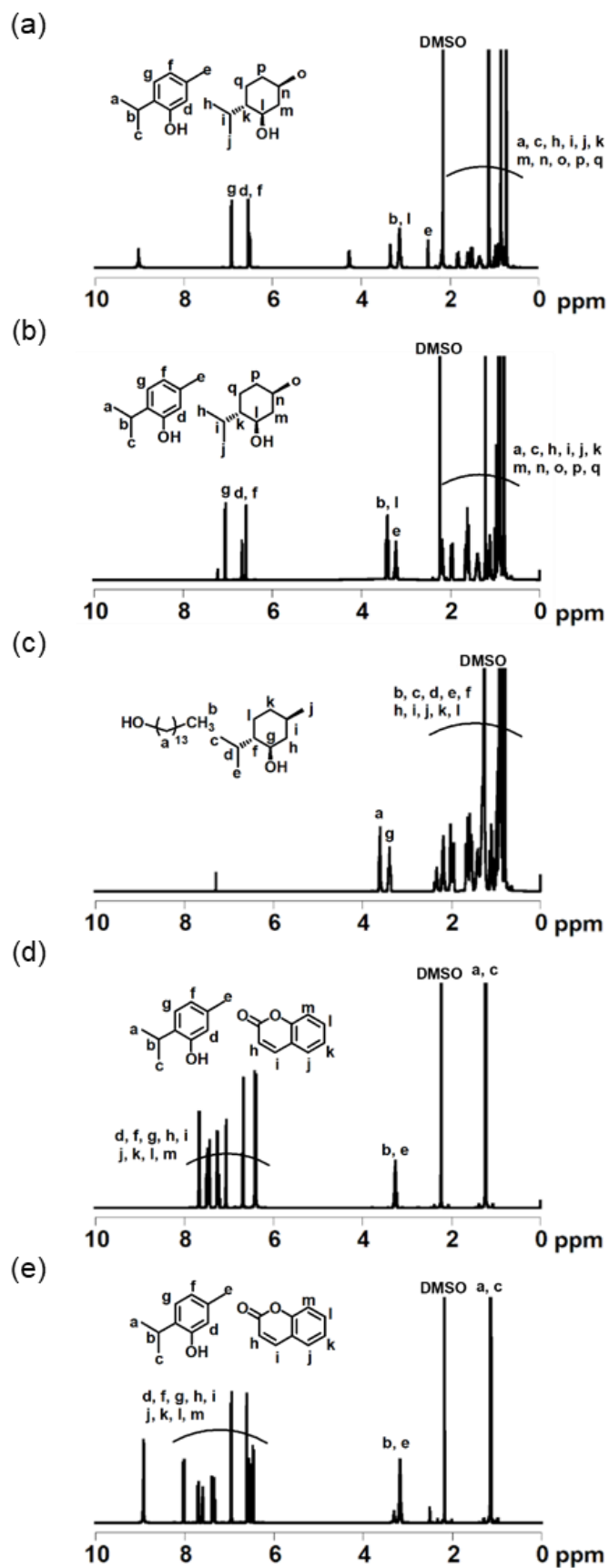
$^1\text{H}$  NMR (400 MHz) spectra were recorded with a JEOL JNM-ECX400. FT-IR spectra were obtained with a JASCO FT/IR-210 spectrometer. The dyad tacticity of PNIPAM was evaluated from the methylene proton peaks recorded in  $\text{DMSO-}d_6$  at 150 °C. 2D NMR spectra were recorded on a JEOL ECZ-600 at a resonant frequency of 600 MHz. SEC measurement was conducted on a Tosoh HPLC HLC-8220 system equipped with refractive index and ultraviolet detectors at 40 °C. The column set was as follows: four consecutive hydrophilic vinyl polymer-based gel columns (TSK-GELs:  $\alpha$ -M,  $\alpha$ -4000,  $\alpha$ -3000,  $\alpha$ -2500) and a guard column (TSK-guardcolumn  $\alpha$ ]. The samples were run at a flow rate of 1.0 mL/min using DMF containing 10 mM LiBr as the eluent. The number-average molecular weight ( $M_n$ ) and molecular weight distribution ( $M_w/M_n$ ) were estimated relative to polystyrene standards (Tosoh) ranging from 1050 to 1090000. The UV-vis spectra were recorded on JASCO V-630BIO UV-vis spectrophotometer. The transmittance of the aqueous polymer solution was recorded on a JASCO V-630BIO UV-vis spectrophotometer equipped with a temperature controller (JASCO EHC-716 and EHC-717, respectively).<sup>2</sup>

Tensile tests were performed using a MX2-500N (IMADA Co., Ltd.) with a digital force gauge ZTA-500N machine (IMADA Co., Ltd.). For the preparation of the dog bone-shaped specimen (effective gauge dimensions: length = 12 mm, width = 2 mm, and thickness = 1.0 mm), NADEM and DMPA (0.01 mol % for NADEM) were introduced into a Teflon mold, followed by photolyzing with a 365 nm wavelength LED-UV light (LNSP-100UV3-365-FN, CCS Inc., 10 cm away, LED = 130 mW/cm<sup>2</sup>) under ambient conditions for 1 min. The specimen was subjected to a tensile test.

**Table S1.** Miscibility of NADESs with common solvents and solubility of NIAPM in NADESs

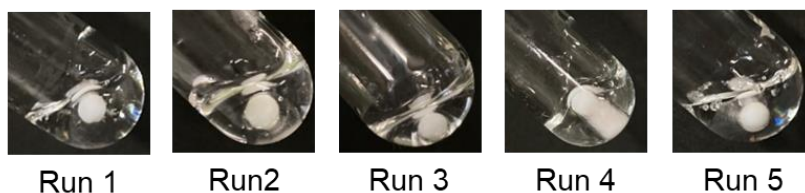
Solvent /monomer	Thy/Men (1/1)	Thy/Men (1/2)	Tdc/Men (1/2)	Thy/Cou (1/1)	Thy/Cou (2/1)
H <sub>2</sub> O	-	-	-	-	-
Acetone	+	+	+	+	+
Chloroform	+	+	+	+	+
Dichloromethane	+	+	+	+	+
Diethyl ether	+	+	+	+	+
Ethanol	+	+	+	+	+
Ethyl acetate	+	+	+	+	+
Methanol	+	+	+	+	+
<i>n</i> -Hexane	+	+	+	+	+
THF	+	+	+	+	+
DMF	+	+	+	+	+
NIPAM	++	++	++	++	++

+ : Miscible at room temperature. - : Immiscible at room temperature. ++ : Soluble at room temperature ([M] = 25 wt%).



**Figure S1.** <sup>1</sup>H NMR spectra (DMSO-*d*<sub>6</sub>) of NADESs: (a) Thy/Men (1/1), (b) Thy/Men (1/2), (c) Tdc/Men (1/2), Thy/Cou (1/1), and Thy/Cou (2/1).

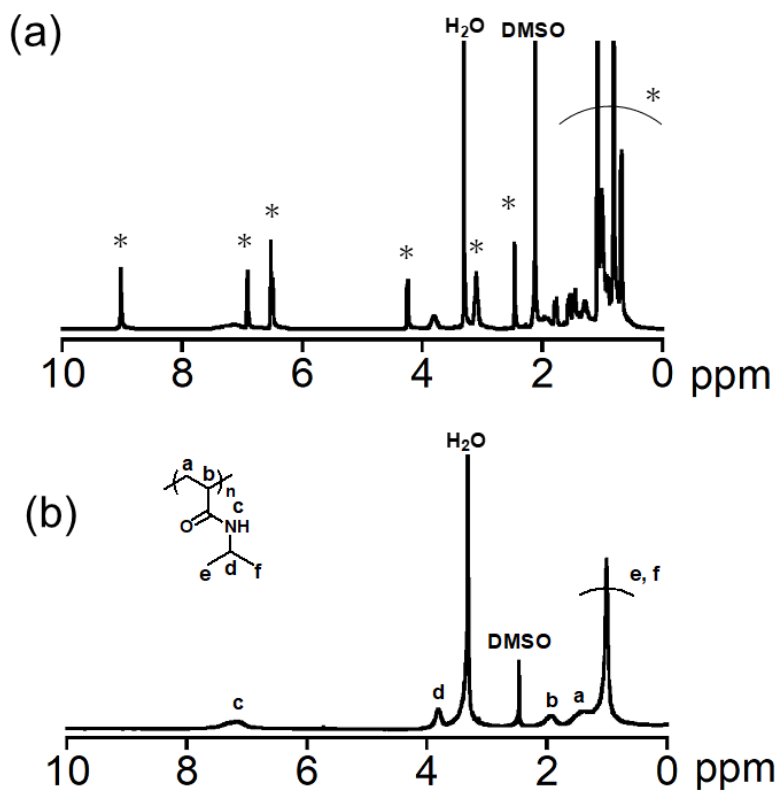
### Polymerization at 60 °C



### Polymerization at 90 °C



**Figure S2.** Appearance of polymerized products obtained by free radical polymerization of NIPAM in various NADESs (see Table 1 and Table S2 for detailed polymerization conditions).



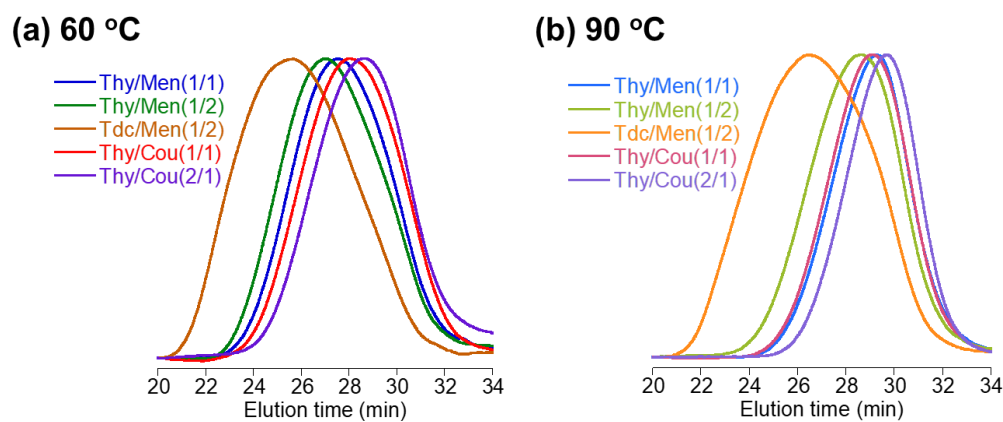
**Figure S3.** <sup>1</sup>H NMR spectra (DMSO-*d*<sub>6</sub>) of (a) crude product prepared by the thermally-induced free radical polymerization of NIPAM in Thy/Men (1/1) (Run 1 in Table 1) and (b) PNIPAM purified by reprecipitation into diethyl ether and isolated by filtration. The asterisk corresponds to the peaks attributed to Thy/Men (1/1).

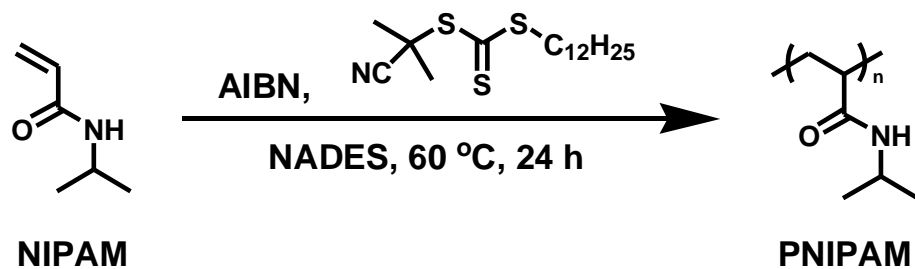


**Table S2.** Thermally-induced free radical polymerization of NIPAM in hydrophobic NADESs at 90 °C<sup>a)</sup>

Run	Solvent	Conv. <sup>b)</sup> / Yield <sup>c)</sup>	$M_n$ <sup>d)</sup>	$M_w/M_n$ <sup>d)</sup>
		(%)	(SEC)	(SEC)
1	Thy/Men (1/1)	98/68	25000	1.89
2	Thy/Men (1/2)	98/76	33000	2.05
3	Tdc/Men (1/2)	>99/86	67000	2.73
4	Thy/Cou (1/1)	-/81	26000	1.89
5	Thy/Cou (2/1)	78/69	13000	1.91

<sup>a)</sup> Polymerization with AIBN at 90 °C for 24 h.  $[I]_0/[M]_0 = 1/100$ .  $[M] = 25$  wt%. <sup>b)</sup> Calculated using <sup>1</sup>H NMR spectroscopy in DMSO-*d*<sub>6</sub>. <sup>c)</sup> Diethyl ether insoluble fraction. <sup>d)</sup> Measured by size-exclusion chromatography (SEC) using a polystyrene standard in *N,N*-dimethylformamide (DMF, 10 mM LiBr).

**Figure S4.** SEC curves (RI traces, DMF, LiBr) of PNIPAMs obtained by free radical polymerization of NIPAM in various NADESs at (a) 60 °C and (b) 90 °C (see Table 1 and Table S2 for detailed polymerization conditions).

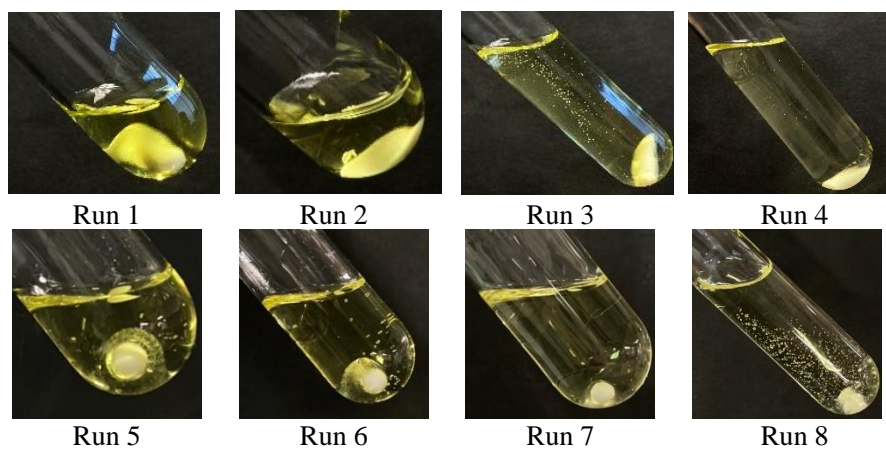


**Scheme S1.** Thermally-induced RAFT polymerization of NIPAM in NADES.

**Table S3.** Thermally-induced RAFT polymerization of NIPAM in NADES <sup>a)</sup>

Run	Solvent	[I] <sub>0</sub> /[CTA] <sub>0</sub> /[M] <sub>0</sub>	Conv. <sup>b)</sup> /Yield <sup>c)</sup> (%)	<i>M<sub>n</sub></i> <sup>b)</sup> (theory)	<i>M<sub>n</sub></i> <sup>d)</sup> (SEC)	<i>M<sub>w</sub></i> / <i>M<sub>n</sub></i> <sup>d)</sup> (SEC)
1		1/2/100	99/40	6000	8000	1.21
2	Thy/Men	1/2/200	92/60	11000	17000	1.19
3	(1/1)	1/2/400	55/44	16000	21000	1.27
4		1/2/1000	28/24	14000	25000	1.35
5		1/2/100	>99/31	5600	12000	1.18
6	Tdc/Men	1/2/200	>99/83	11000	18000	1.21
7	(1/2)	1/2/400	>99/94	22000	32000	1.28
8		1/2/1000	97/87	55000	52000	1.34

<sup>a)</sup> Polymerization with AIBN at 60 °C for 24 h. [M] = 25 wt%. <sup>b)</sup> Calculated by <sup>1</sup>H NMR in DMSO-*d*<sub>6</sub>. <sup>c)</sup> Diethyl ether-insoluble part. <sup>d)</sup> Measured by size-exclusion chromatography (SEC) using polystyrene standard in *N,N*-dimethylformamide (DMF, 10 mM LiBr).



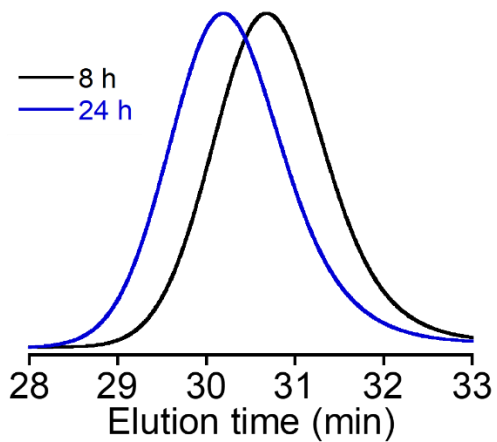
**Figure S5.** Appearance of polymerized products obtained by thermally-induced RAFT polymerization of NIPAM at different  $[M]/[CTA]$  ratios in NADESs (Run 1–Run 4 : Thy/Men (1/1), Run 5–Run 8 : Tdc/Men (1/2) in Table S3).

**Table S4.** Thermally-induced RAFT polymerization of NIPAM in NADESs <sup>a)</sup>

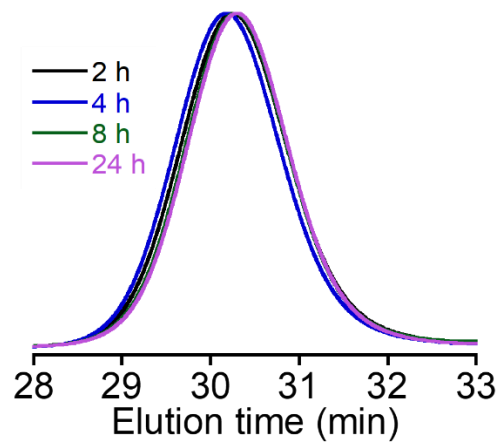
Run	Solvent	Time (h)	Conv. <sup>b)</sup> (%)	$M_n$ <sup>b)</sup> (theo)	$M_n$ <sup>c)</sup> (SEC)	$M_w/M_n$ <sup>c)</sup> (SEC)
1		1	0	-	-	-
2	Thy/Men (1/1)	2	10	1500	-	-
3		4	26	3300	-	-
4		8	75	9000	8200	1.15
5		24	99	12000	11000	1.17
6		1	0	-	-	-
7	Thy/Men (1/2)	2	2	600	-	-
8		4	64	7600	7400	1.17
9		8	85	10000	9000	1.18
10		24	99	12000	10000	1.20
11		1	48	5800	-	-
12	Tdc/Men (1/2)	2	92	11000	11000	1.15
13		4	99	12000	11000	1.14
14		8	99	12000	11000	1.13
15		24	99	12000	10000	1.14
16		1	1	460	-	-
17	Thy/Cou (1/1)	2	15	2000	-	-
18		4	71	8400	16000	1.21
19		8	76	8900	15000	1.21
20		24	90	11000	16000	1.24
21		1	0	-	-	-
22	Thy/Cou (2/1)	2	0	-	-	-
23		4	28	3500	-	-
24		8	59	7000	6400	1.19
25		24	78	9000	7600	1.23
26		DMF	3	82	10000	9100
27	6		94	11000	9600	1.22

<sup>a)</sup> Polymerization with AIBN at 60 °C for 24 h.  $[I]_0/[CTA]_0/[M]_0 = 1/2/200$ .  $[M] = 25$  wt%. <sup>b)</sup> Calculated by <sup>1</sup>H NMR in DMSO-*d*<sub>6</sub>. <sup>c)</sup> Measured by size-exclusion chromatography (SEC) using polystyrene standard in *N,N*-dimethylformamide (10 mM LiBr).

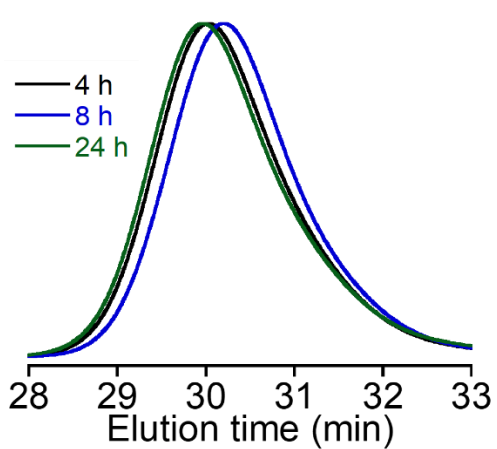
(a) Thy/Men (1/1)



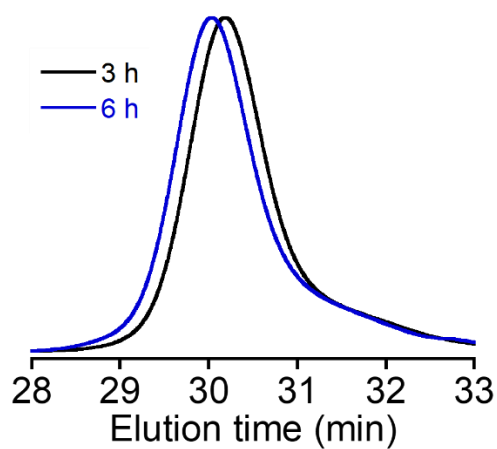
(b) Tdc/Men (1/2)



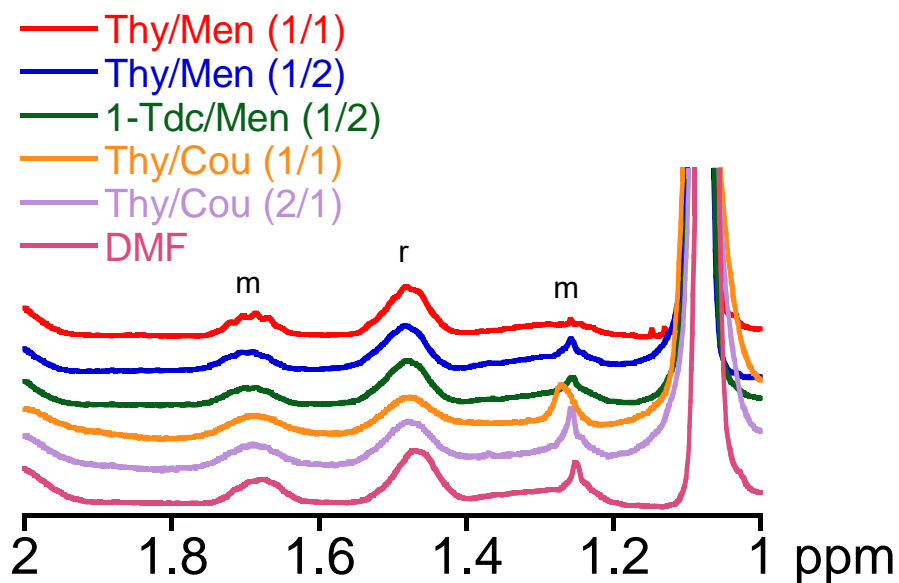
(c) Thy/Cou (1/1)



(d) DMF



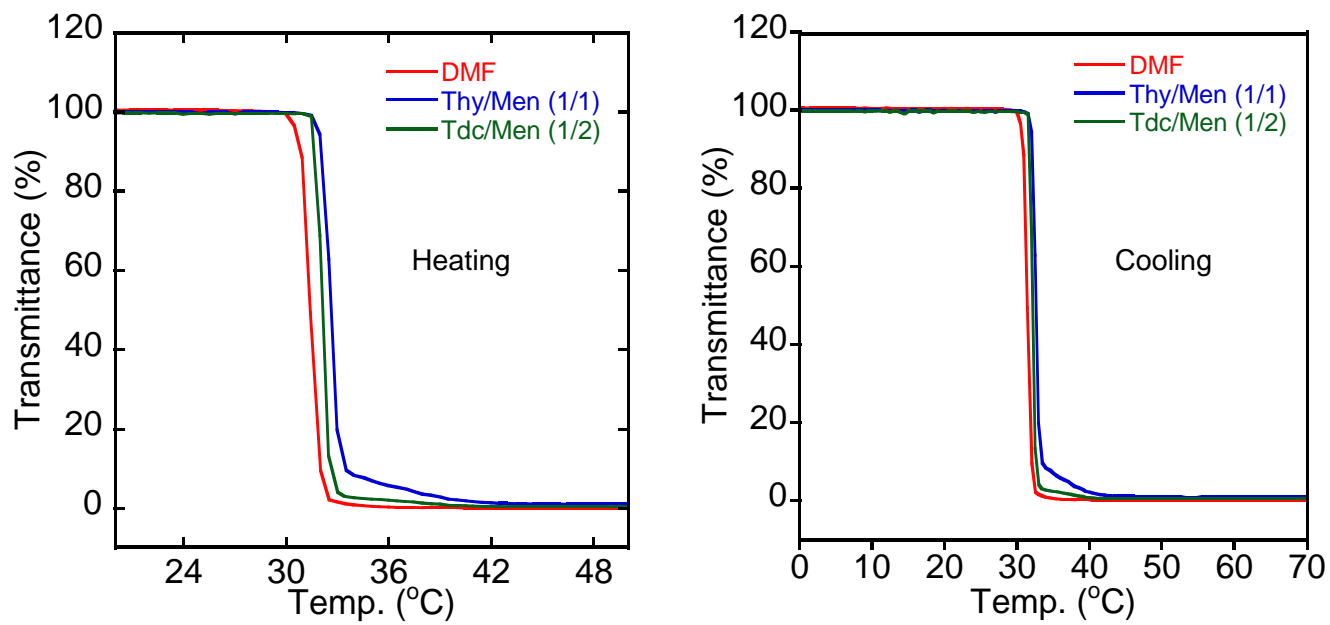
**Figure S6.** SEC curves (RI traces, DMF, LiBr) of PNIPAMs obtained by thermally-induced RAFT polymerization of NIPAM in (a-c) NADESs and (d) DMF (Table S4).



**Figure S7.**  $^1\text{H}$  NMR spectra ( $\text{DMSO-}d_6$ ,  $150\text{ }^\circ\text{C}$ ) of PNIPAMs obtained by thermally-induced RAFT polymerization of NIPAM in hydrophobic NADESs (Runs 5, 10, 15, 20, 25, 27 in Table S4).

**Table S5.** Summary of tacticity of PNIPAMs prepared in different NADESs

Solvent	meso (m)	racemo (r)
Thy/Men (1/1)	48	52
Thy/Men (1/2)	51	49
Tdc/Men (1/2)	49	51
Thy/Cou (1/1)	54	46
Thy/Cou (2/1)	54	46
DMF	54	46



**Figure 8.** Temperature dependence of the transmittance at 500 nm of aqueous solutions of PNIPAMs prepared in NADESs, Thy/Men (1/1) and Tdc/Men (1/2), and DMF.

**Table S6.** Photo-induced free radical polymerization of NIPAM under UV light (Hg lamp) in various NADESs <sup>a)</sup>

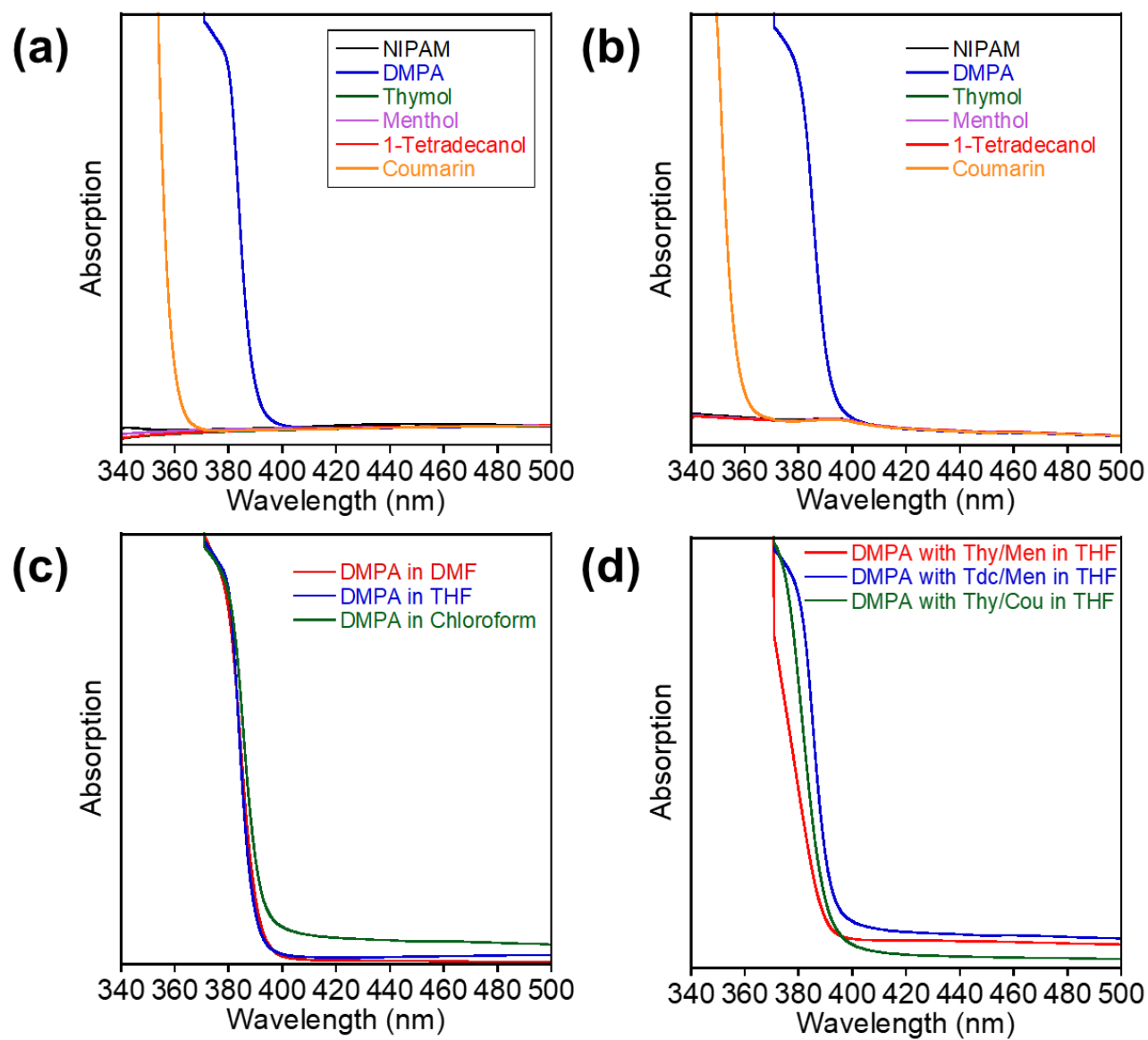
Run	Solvent	Conv. <sup>b)</sup> (%)	Yield <sup>c)</sup> (%)	$M_n$ <sup>d)</sup> (SEC)	$M_w/M_n$ <sup>d)</sup> (SEC)
1	Thy/Men (1/1)	96	30	83000	1.61
2	Thy/Men (1/2)	99	63	68000	2.03
3	Tdc/Men (1/2)	99	60	190000	2.06
4	Thy/Cou (1/1)	<1	-	-	-
5	Thy/Cou (2/1)	<1	-	-	-

<sup>a)</sup> Polymerization with DMPA at room temperature for 90 min under air.  $[I]_0/[M]_0 = 1/100$ .  $[M] = 30$  wt%. <sup>b)</sup> Calculated by  $^1\text{H}$  NMR in  $\text{DMSO-}d_6$ . <sup>c)</sup> Diethyl ether-insoluble part. <sup>d)</sup> Measured by size-exclusion chromatography (SEC) using polystyrene standard in *N,N*-dimethylformamide (10 mM LiBr).



**Figure S9.** Appearance of polymerized products obtained by photo-induced free radical polymerization of NIPAM in various NADESs (see Table S6).



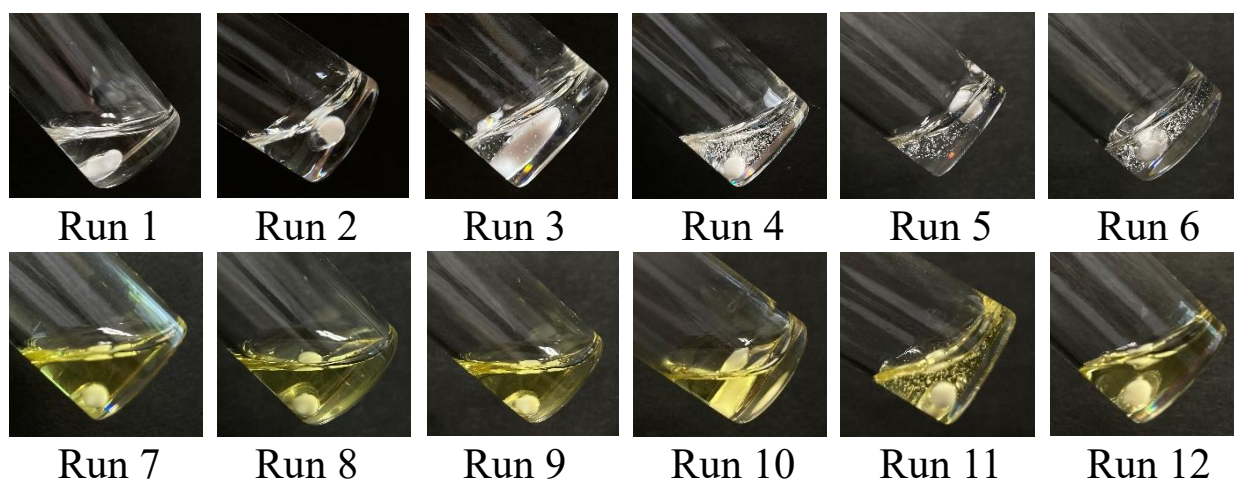


**Figure S10.** UV-vis spectra of (a,b) NADES components, monomer (NIPAM), and photoinitiator (DMPA) in (a) CHCl<sub>3</sub> and (b) THF. UV-vis spectra of (c) DMPA in different solvents and (d) DMPA with NADESs in THF.

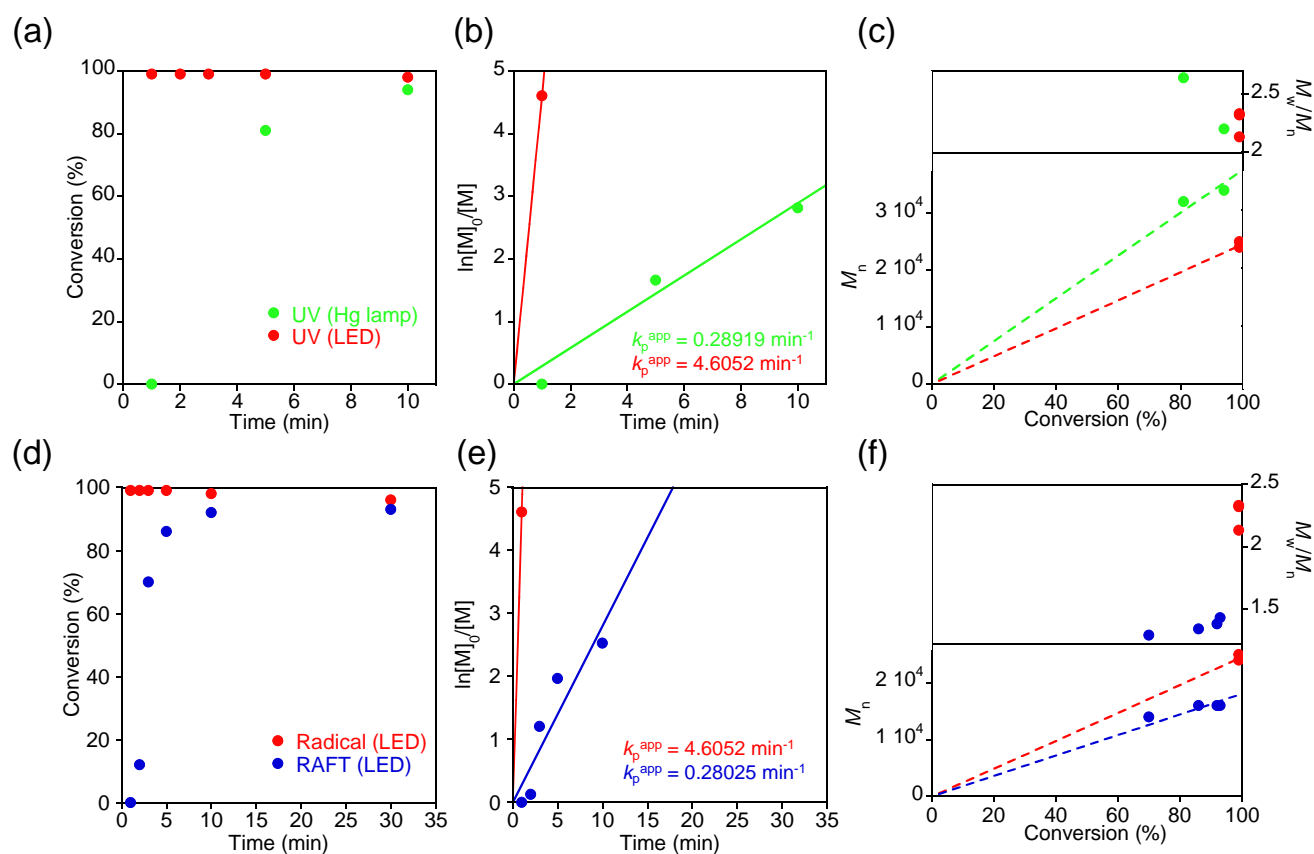
**Table S7.** Photo-induced free radical and RAFT polymerization of NIPAM in Thy/Men (1/1) NADES using different lights <sup>a)</sup>

Run	[I] <sub>0</sub> /[CTA] <sub>0</sub> /[M] <sub>0</sub> (light)	Time (min)	Conv. <sup>b)</sup> (%)	<i>M<sub>n</sub></i> <sup>b)</sup> (theo)	<i>M<sub>n</sub></i> <sup>c)</sup> (SEC)	<i>M<sub>w</sub></i> / <i>M<sub>n</sub></i> <sup>c)</sup> (SEC)
1	1/0/100	1	0	-	-	-
2	(Hg lamp, 6.0 mW/cm <sup>2</sup> )	5	81	-	32000	2.64
3		10	94	-	34000	2.20
4	1/0/100	1	99	-	24000	2.33
5	(LED-UV light, 330 mW/cm <sup>2</sup> )	2	99	-	24000	2.13
6		3	99	-	25000	2.32
7		1	0	-	-	-
8		2	12	1700	-	-
9	1/1/100	3	70	8000	14000	1.29
10	(LED-UV light, 330 mW/cm <sup>2</sup> )	5	86	10000	16000	1.34
11		10	92	11000	16000	1.38
12		30	93	11000	16000	1.43

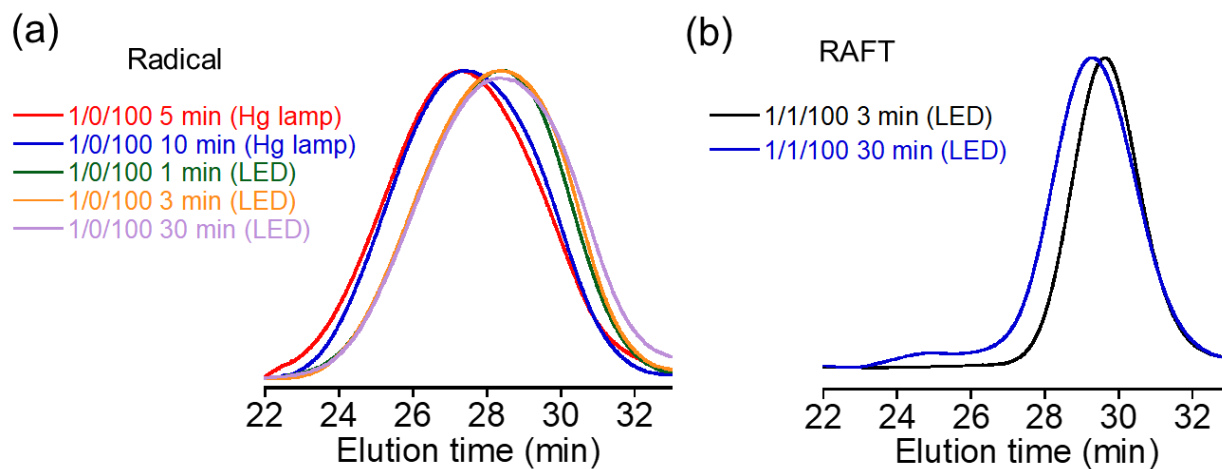
<sup>a)</sup> Polymerization with DMPA at room temperature under air. [M] = 30 wt%. <sup>b)</sup> Calculated by <sup>1</sup>H NMR in DMSO-*d*<sub>6</sub>. <sup>c)</sup> Diethyl ether-insoluble part. <sup>d)</sup> Measured by size-exclusion chromatography (SEC) using polystyrene standard in *N,N*-dimethylformamide (DMF, 10 mM LiBr).



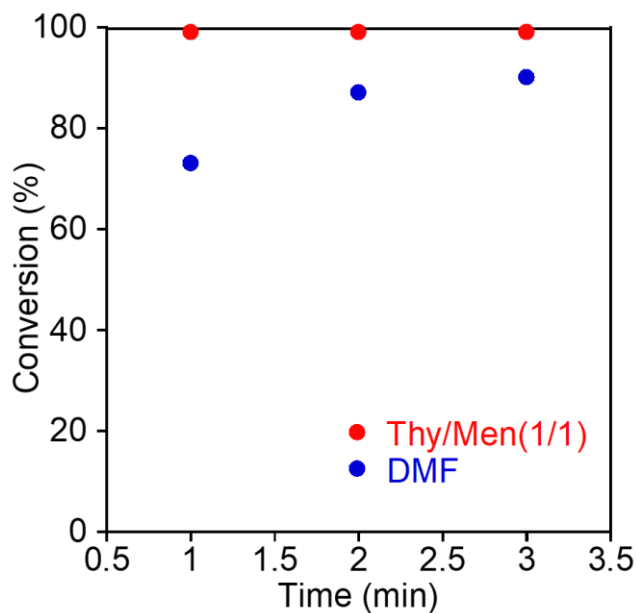
**Figure S11.** Appearance of polymerized products obtained by free radical and RAFT polymerizations of NIPAM in Thy/Men (1/1) NADES (Table S7).



**Figure S12.** (a) Time-conversion and (b) first-order kinetic plots for the photo-induced free radical polymerization of NIPAM in Thy/Men (1/1) NADES under different UV lights (Hg lamp and LED). (c) Number-average molecular weight and polydispersity as a function of conversion. (d) Time-conversion and (e) first-order kinetic plots for the photo-induced free radical and RAFT polymerizations of NIPAM in Thy/Men (1/1) NADES under LED-UV light. (f) Number-average molecular weight and polydispersity as a function of conversion.



**Figure S13.** SEC curves (RI traces, DMF, LiBr) of PNIPAMs obtained by photo-induced (a) free radical and (b) RAFT polymerizations under air in Thy/Men (1/1) NADES (see Table S7 for detailed conditions).



**Figure S14.** Time-conversion plots of photo-induced free radical polymerization of NIPAM under LED-UV light in Thy/Men (1/1) NADES and DMF.

**Table S8.** Photo-induced RAFT polymerization of NIPAM under UV light (LED-UV) in Tdc/Men (1/2) NADES <sup>a)</sup>

Run	Time (min)	Conv. <sup>b)</sup> (%)	$M_n$ <sup>b)</sup> (theo)	$M_n$ <sup>c)</sup> (SEC)	$M_w/M_n$ <sup>c)</sup> (SEC)
1	1	0	-	-	-
2	2	67	8000	19000	1.38
3	3	88	10000	21000	1.51
4	5	95	11000	21000	1.58
5	10	99	12000	19000	1.61
6	30	98	11000	17000	1.51

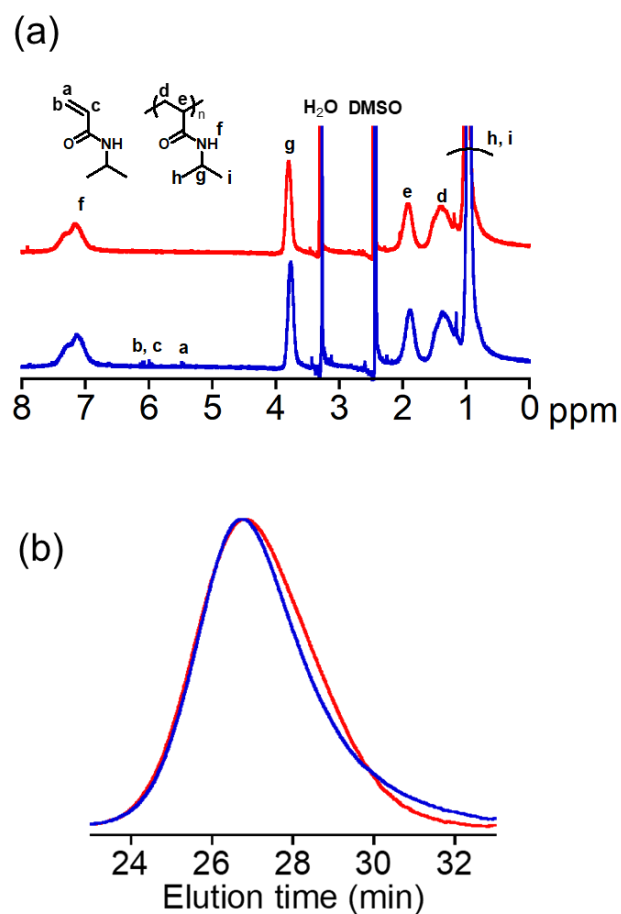
<sup>a)</sup> Polymerization with DMPA at room temperature under air.  $[I]_0/[CTA]_0/[M]_0 = 1/1/100$ .  $[M] = 30$  wt%.

<sup>b)</sup> Calculated by <sup>1</sup>H NMR in DMSO-*d*<sub>6</sub>. <sup>c)</sup> Measured by size-exclusion chromatography (SEC) using polystyrene standard in *N,N*-dimethylformamide (10 mM LiBr).

**Table S9.** Photo-induced RAFT polymerization of NIPAM under UV light (LED light) in hydrophobic NADESs <sup>a)</sup>

Run	Solvent	[I] <sub>0</sub> /[CTA] <sub>0</sub> /[M] <sub>0</sub>	Conv. <sup>b)</sup> /Yield <sup>c)</sup> (%)	<i>M<sub>n</sub></i> <sup>b)</sup> (theory)	<i>M<sub>n</sub></i> <sup>d)</sup> (SEC)	<i>M<sub>w</sub></i> / <i>M<sub>n</sub></i> <sup>d)</sup> (SEC)
1		1/1/100	>99/88	11000	26000	1.39
2	Thy/Men (1/1)	1/1/200	>99/91	22000	28000	1.36
3		1/1/500	>99/86	56000	44000	1.54
4		1/1/1000	>99/75	110000	69000	1.76
5		1/1/100	95/72	11000	22000	1.36
6	Tdc/Men (1/2)	1/1/200	>99/79	22000	30000	1.34
7		1/1/500	>99/82	57000	50000	1.56
8		1/1/1000	96/89	110000	60000	1.94

<sup>a)</sup> Polymerization with DMPA at room temperature for 30 min under air. [M] = 30 wt%. <sup>b)</sup> Calculated by <sup>1</sup>H NMR in DMSO-*d*<sub>6</sub>. <sup>c)</sup> Diethyl ether-insoluble part. <sup>d)</sup> Measured by size-exclusion chromatography (SEC) using polystyrene standards in *N,N*-dimethylformamide (DMF, 10 mM LiBr).

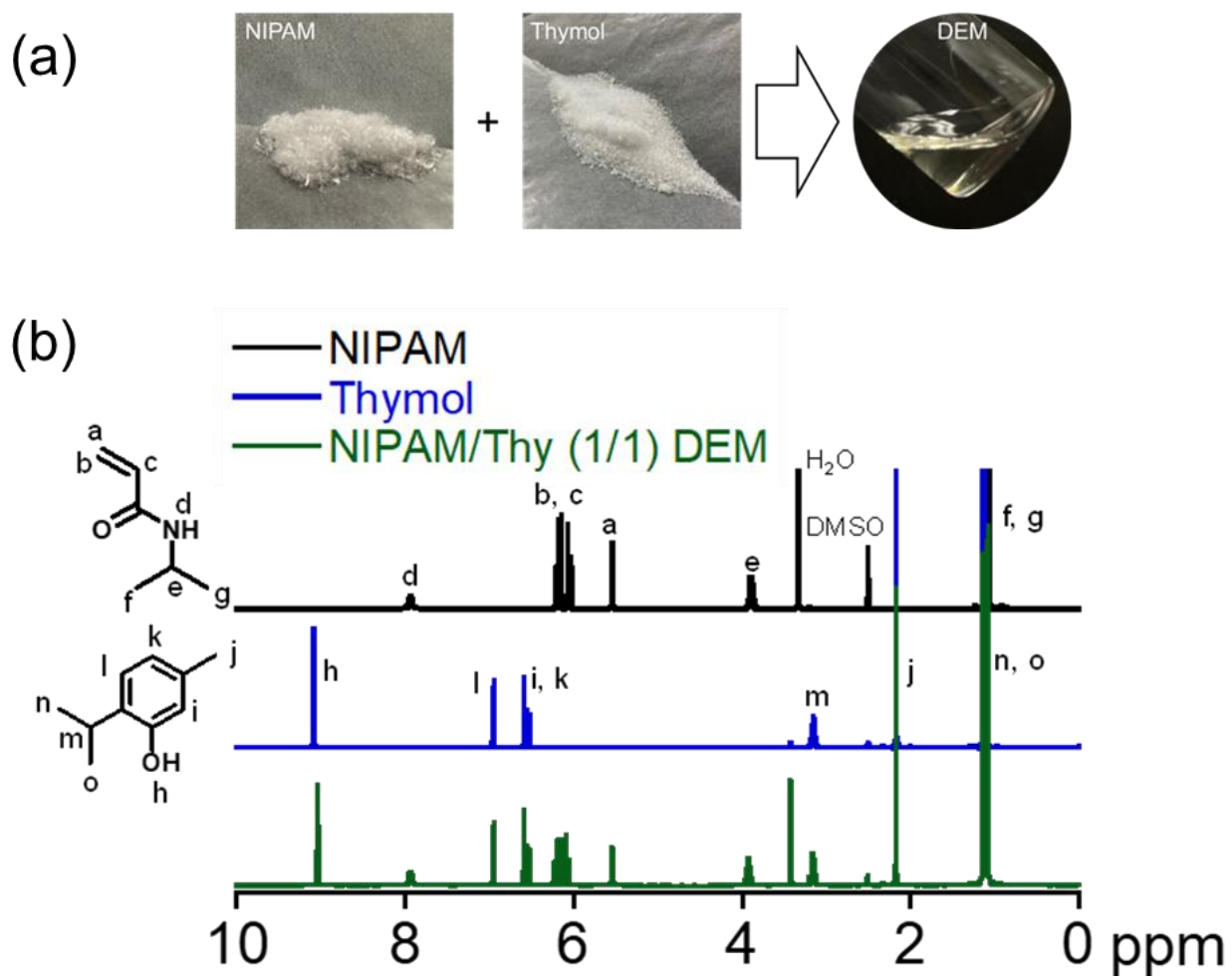


**Figure S15.** (a)  $^1\text{H}$  NMR spectra and (b) SEC curves (RI detector, DMF, LiBr) of PNIPAMs obtained by photo-induced RAFT polymerization under air in Tdc/Men (1/2) NADES, which was purified by reprecipitation into diethyl ether, followed by filtration (red line) and by mixing with a distilled water by ultrasonicated (40 kHz) at 30 °C for 5 min, followed by filtration (blue line).

**Table S10.** Characteristics of PNIPAMs obtained by different purification processes <sup>a)</sup>

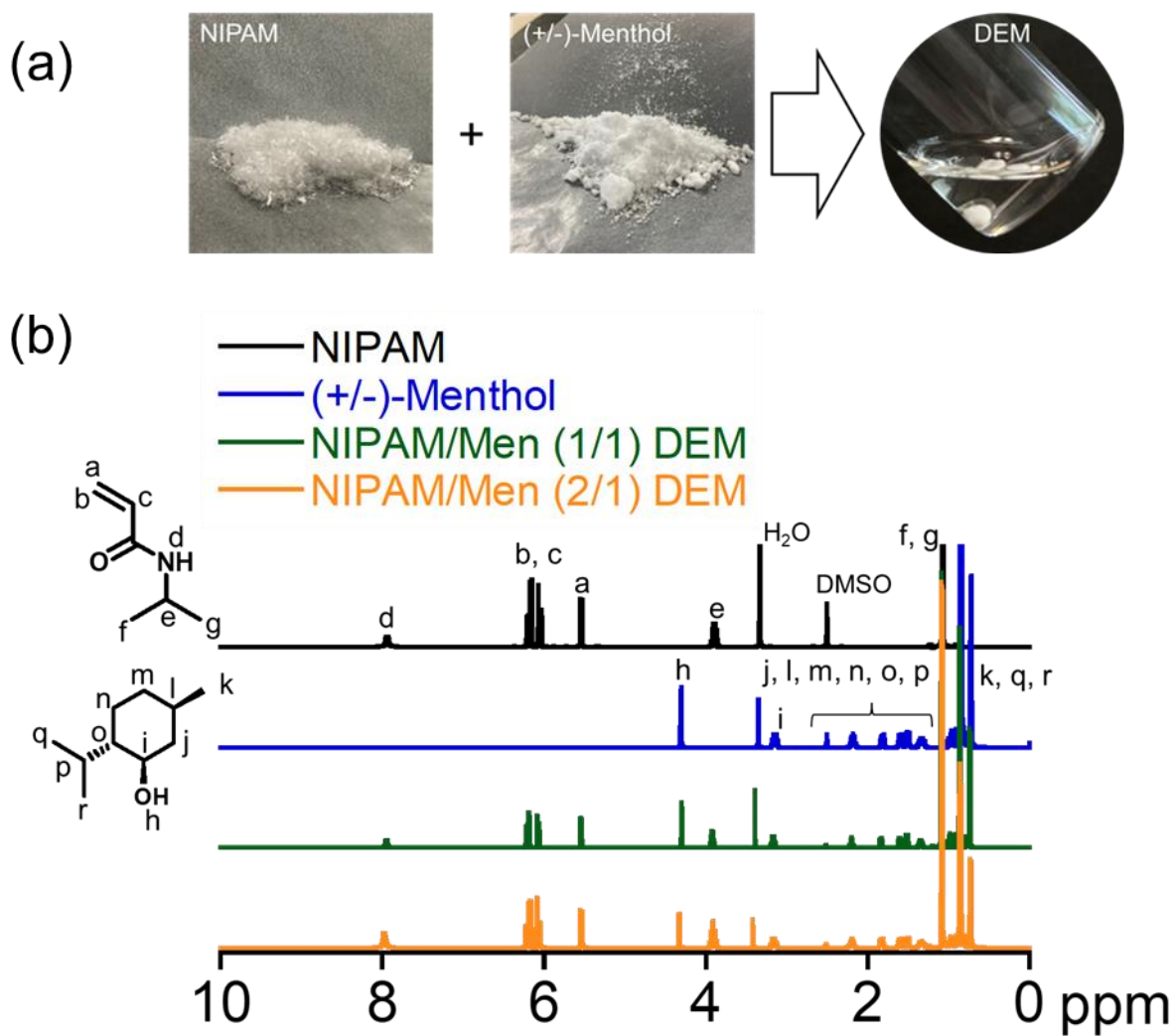
Run	Conv. <sup>b)</sup> (%)	Yield (%)	$M_n$ <sup>b)</sup> (theo)	$M_n$ <sup>c)</sup> (SEC)	$M_w/M_n$ <sup>c)</sup> (SEC)
1	99	82 <sup>d)</sup>	56000	47000	1.64
2	99	57 <sup>e)</sup>	56000	43000	1.80

<sup>a)</sup> Polymerization with DMPA at room temperature for 10 min under LED-UV light (365 nm, 330 mW/cm<sup>2</sup>) in Tdc/Men (1/2). [M] = 30 wt%. <sup>b)</sup> Calculated by  $^1\text{H}$  NMR in DMSO-*d*<sub>6</sub>. <sup>c)</sup> Measured by size-exclusion chromatography (SEC) using polystyrene standard in *N,N*-dimethylformamide (DMF, 10 mM LiBr). <sup>d)</sup> Diethyl ether-insoluble part. <sup>e)</sup> Water-soluble part.

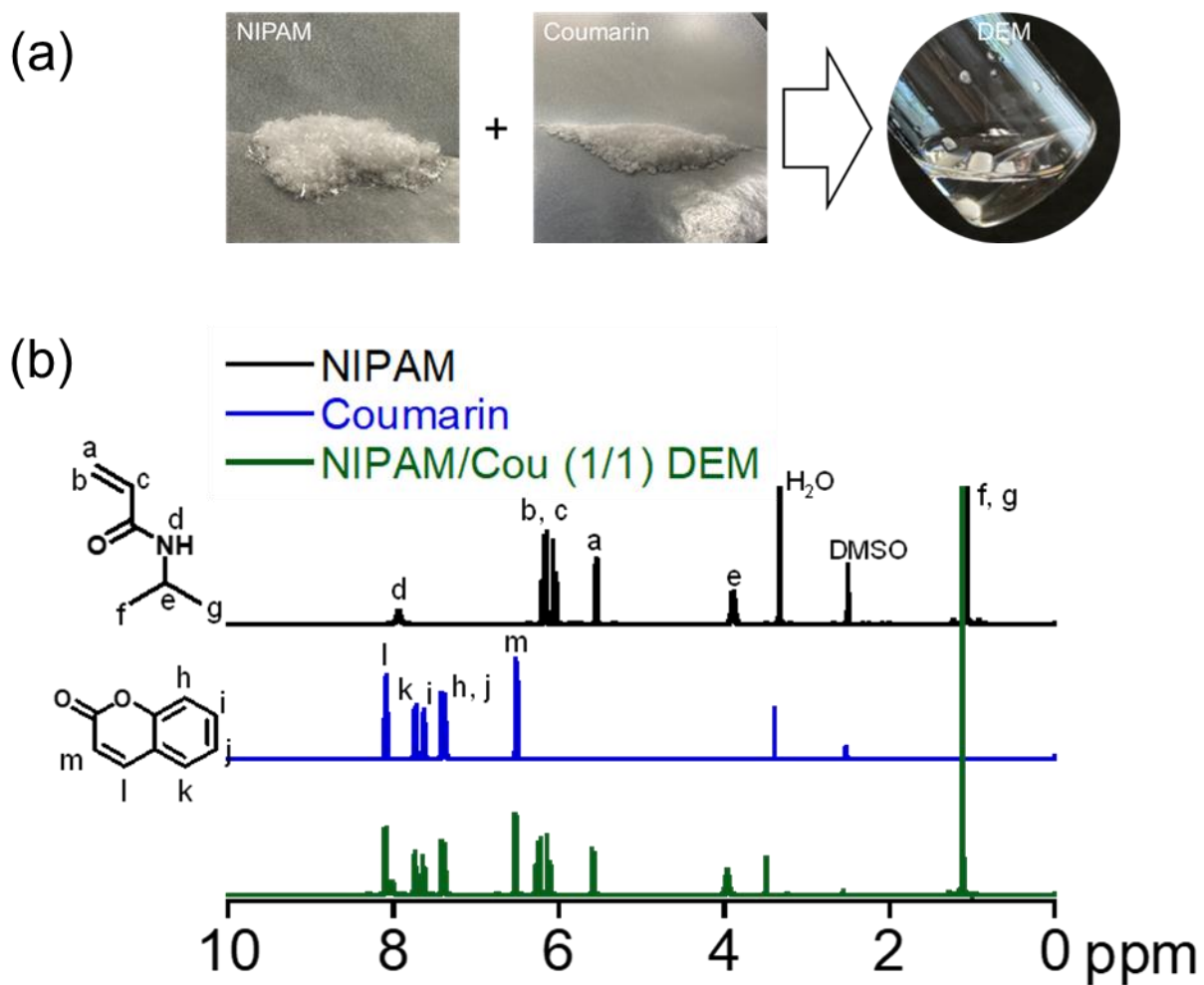


**Figure S16.** (a) Appearance of NIPAM (solid), thymol (solid), and NIPAM/Thy NADEM (liquid), and (b)  $^1\text{H}$  NMR spectra of NIPAM, thymol and NIPAM/Thy (1/1) NADEM in  $\text{DMSO-}d_6$ .

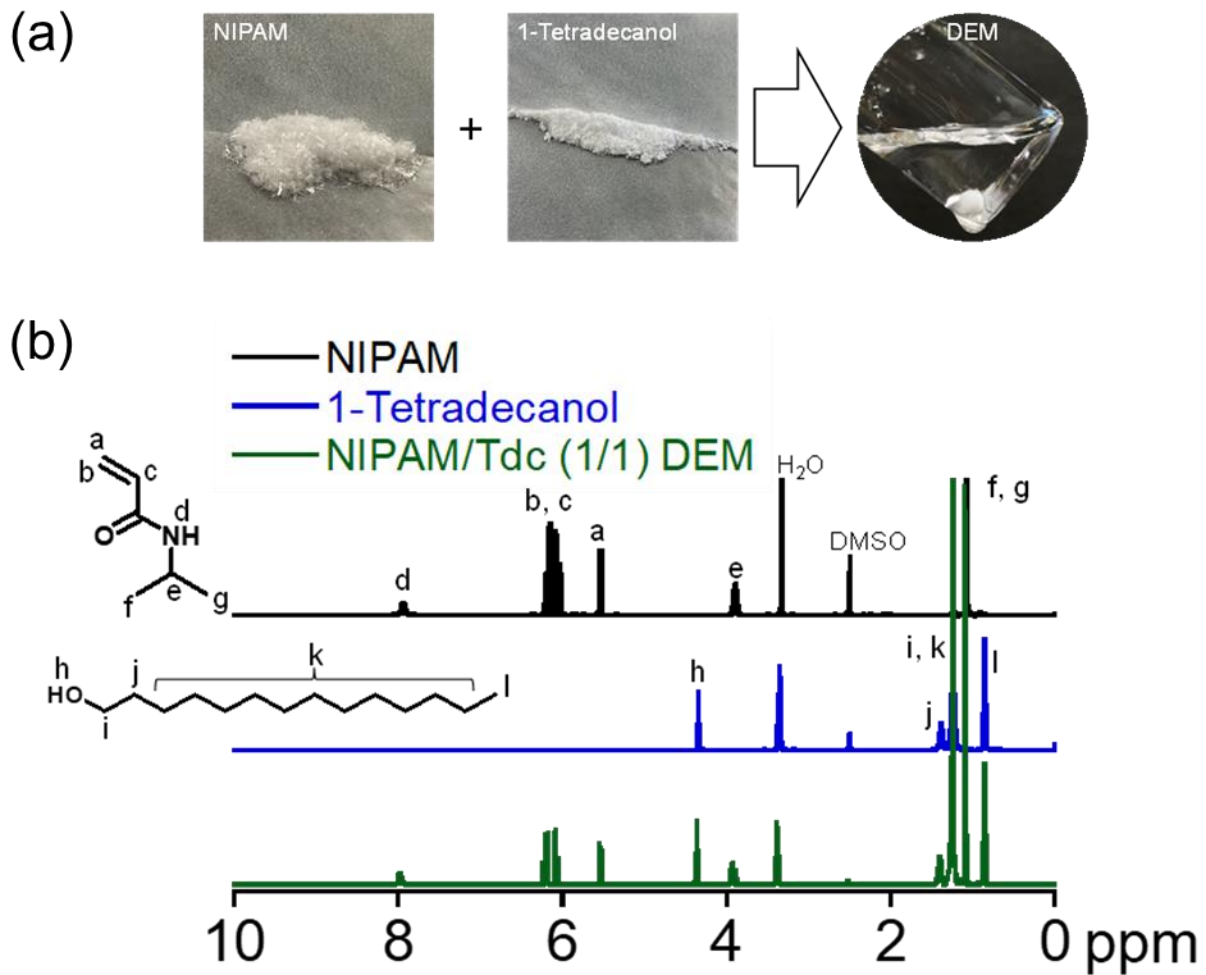




**Figure S17.** (a) Appearance of NIPAM (solid), ( $\pm$ )-menthol (solid), and NIPAM/Men (1/1) NADEM (liquid), and (b)  $^1\text{H}$  NMR spectra of NIPAM, ( $\pm$ )-menthol, and NIPAM/Men (1/1 and 2/1) NADEMs in  $\text{DMSO-}d_6$ .

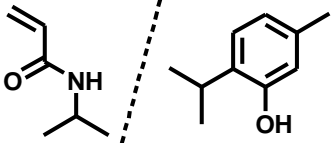
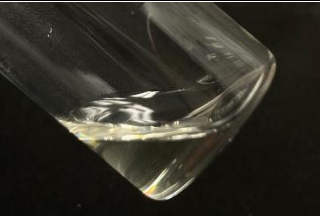
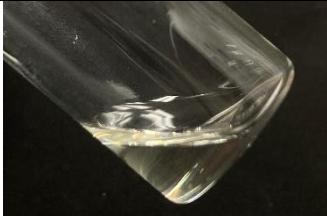
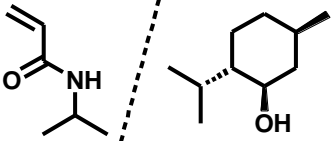


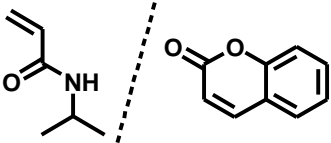


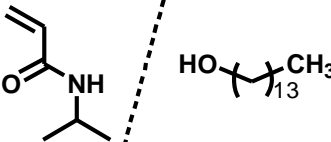




**Figure S18.** (a) Appearance of NIPAM (solid), coumarin (solid), and NIPAM/Cou (1/1) NADEM (liquid), and (b)  $^1\text{H}$  NMR spectra of NIPAM, coumarin, and NIPAM/Cou (1/1) NADEM in  $\text{DMSO-}d_6$ .

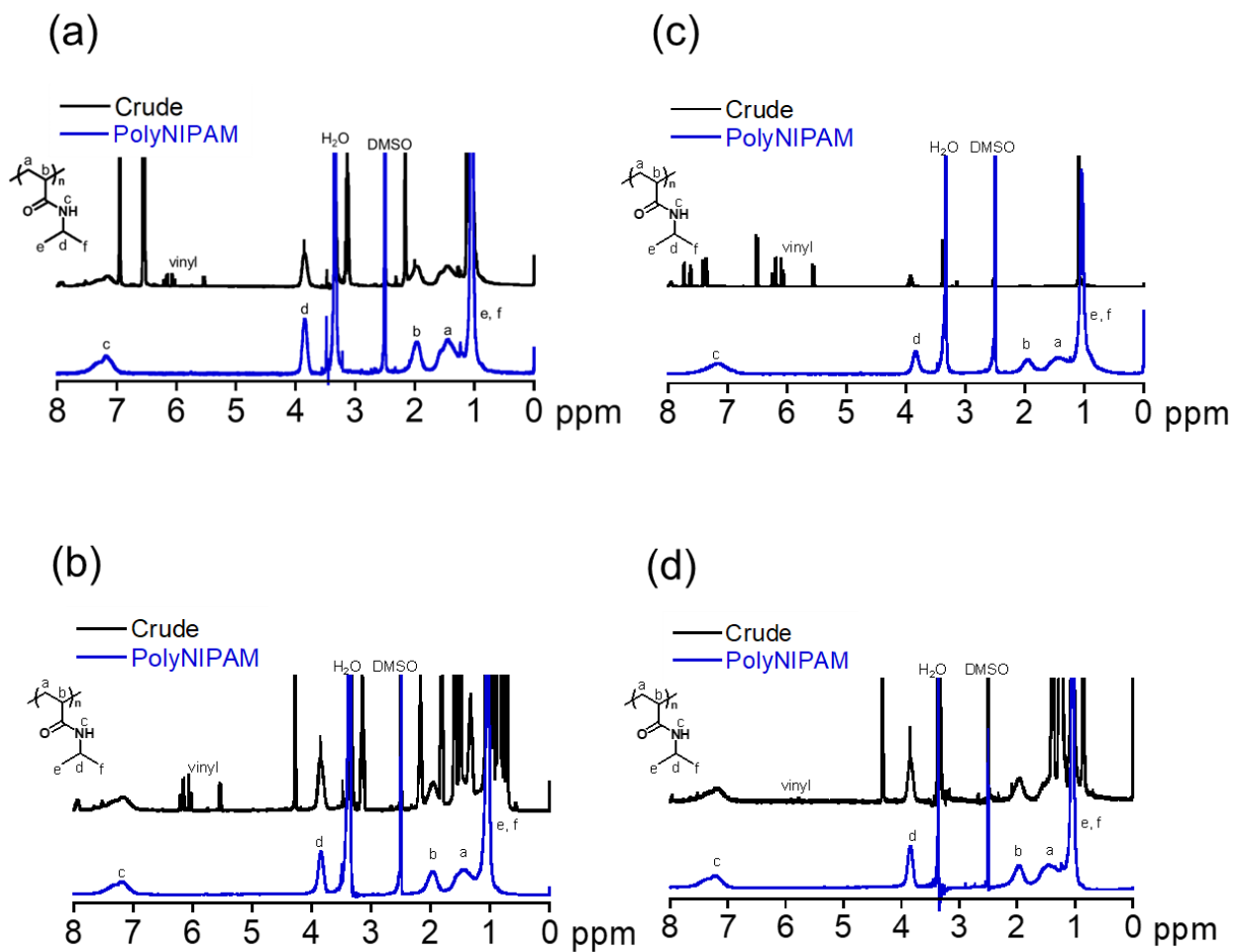


**Figure S19.** (a) Appearance of NIPAM (solid), 1-tetradecanol (solid), and NIPAM/Tdc (1/1) NADEM (liquid), and (b)  $^1\text{H}$  NMR spectra of NIPAM, 1-tetradecanol, and NIPAM/Tdc (1/1) NADEM in  $\text{DMSO-}d_6$ .

**Table S11.** Synthesis of NIPAM-based NADEMs and their appearances

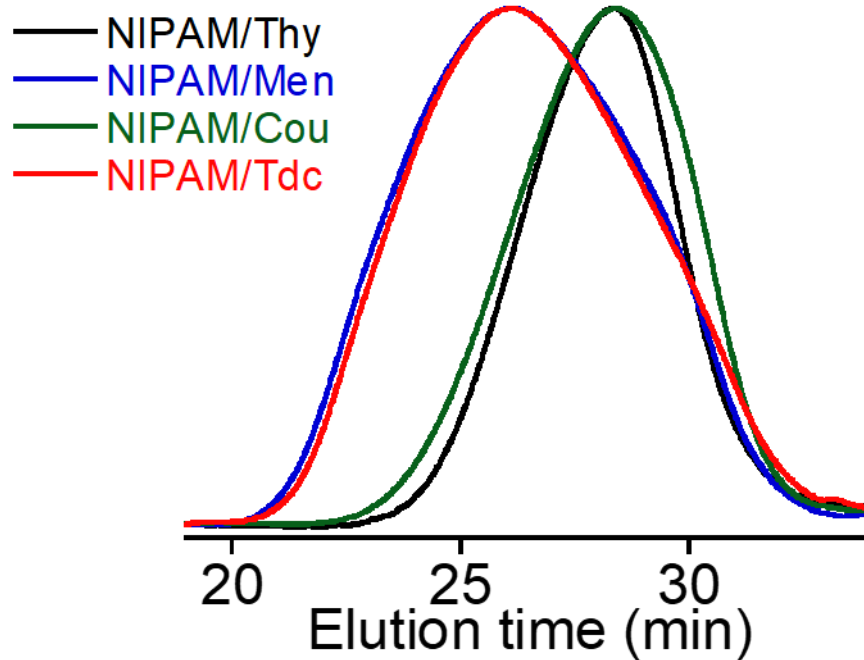
Run	Molar ratio	Appearance	
		Reaction temperature	1 day later <sup>d)</sup>
NIPAM/Thy <sup>a)</sup> 	1/1		
NIPAM/Men <sup>b)</sup> 	1/1		
NIPAM/Cou <sup>c)</sup> 	1/1		
NIPAM/Tdc <sup>c)</sup> 	1/1		

<sup>a)</sup> Mixing at 25 °C for 10 min. <sup>b)</sup> Mixing at 30 °C for 30 min. <sup>c)</sup> Mixing at 50 °C for 30 min. <sup>d)</sup> At room temperature.

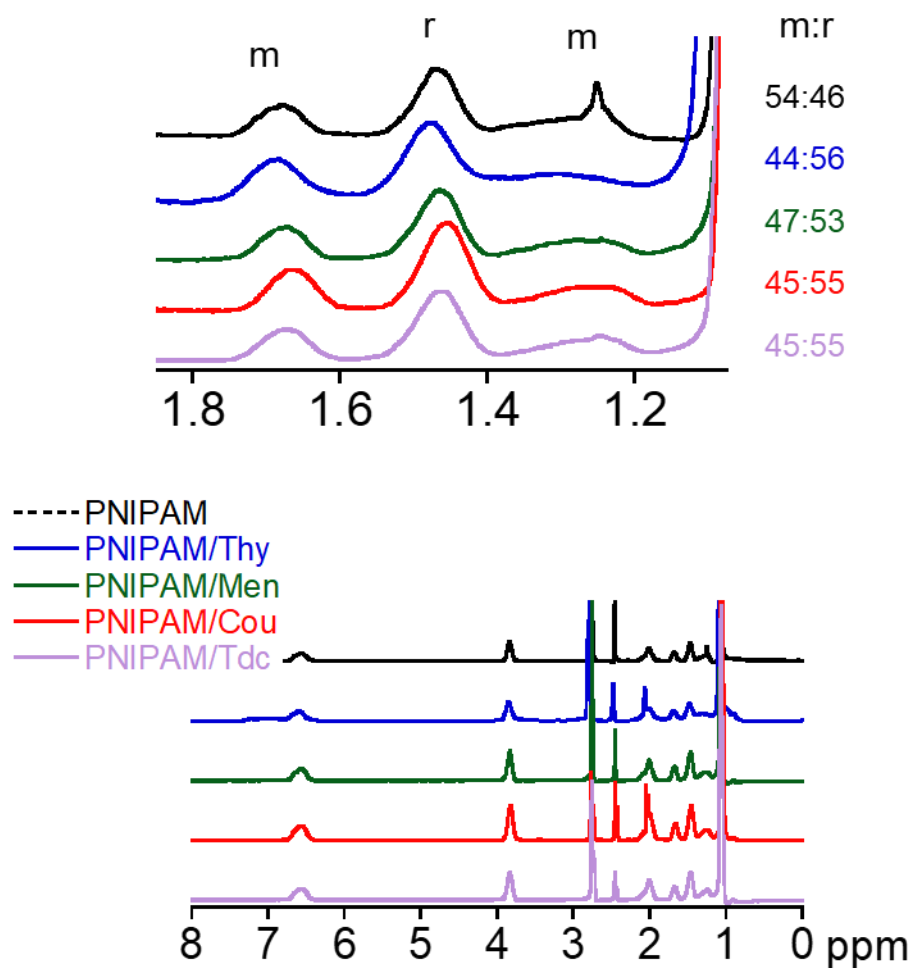


**Figure S20.**  $^1\text{H}$  NMR spectra ( $\text{DMSO-}d_6$ ) of crude products (black line) obtained by photoinduced radical polymerization of (a) NIPAM/Thy (1/1), (b) NIPAM/Men (1/1), (c) NIPAM/Cou (1/1), and (d) NIPAM/Tdc (1/1), and their purified product, PNIPAM, by reprecipitation into diethyl ether.

PNIPAMs obtained from



**Figure S21.** SEC curves (RI traces, DMF, LiBr) of PNIPAMs obtained by photo-induced polymerization of NIPAM-based NADEMs (see Table 2 for detailed polymerization conditions).



**Figure S22.**  $^1\text{H}$  NMR spectra (DMSO- $d_6$ , 150  $^\circ\text{C}$ ) of PNIPAMs obtained by photo-induced polymerization of NIPAM-based NADEMs (see Table 2 for detailed polymerization conditions).

**Table S12.** Photo-induced free radical polymerization of NADEMs under UV light (LED-UV) <sup>a)</sup>

Run	NADEM	Time (s)	Conv. <sup>b)</sup> (%)	$M_n$ <sup>c)</sup> (SEC)	$M_w/M_n$ <sup>c)</sup> (SEC)
1		1	24	59000	3.47
2		2	36	64000	3.06
3	NIPAM/Men	3	42	52000	3.34
4	(1/1)	4	43	46000	3.16
5		5	55	54000	3.09
6		10	91	53000	3.48
7		1	29	49000	2.67
8		2	28	48000	2.90
9	NIPAM/Tdc	3	45	45000	2.90
10	(1/1) <sup>d)</sup>	4	63	41000	3.36
11		5	73	41000	3.17
12		10	99	64000	2.87

<sup>a)</sup> Polymerization with DMPA at room temperature under air.  $[I]_0/[M]_0 = 1/100$ . <sup>b)</sup> Calculated by <sup>1</sup>H NMR in DMSO-*d*<sub>6</sub>. <sup>c)</sup> Measured by size-exclusion chromatography (SEC) using polystyrene standard in *N,N*-dimethylformamide (DMF, 10 mM LiBr). <sup>d)</sup> Polymerization at approximately 50 °C.



**Table S13.** Photo-induced RAFT polymerization of NADEMs under UV light (LED-UV) <sup>a)</sup>

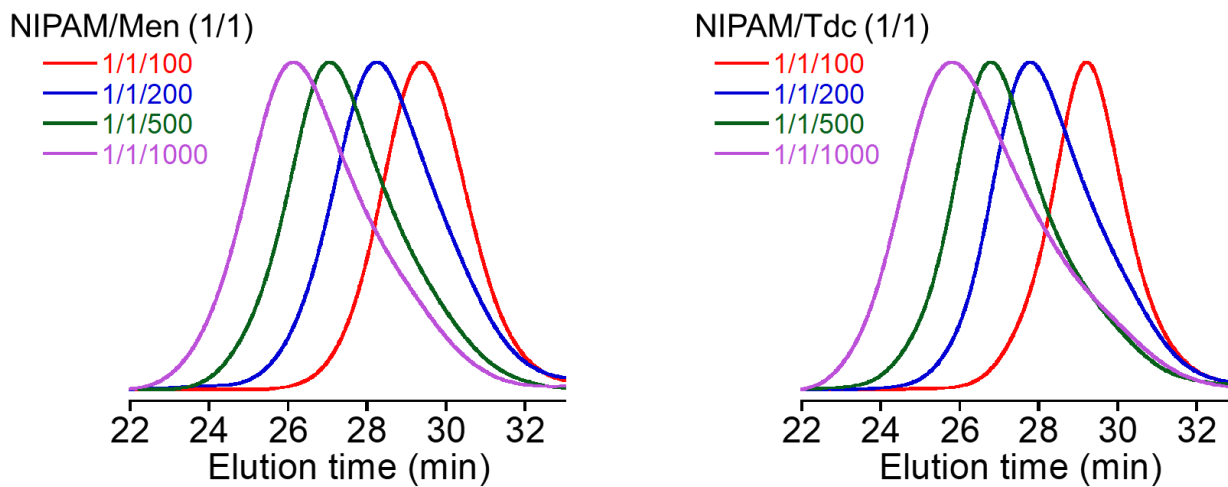
Run	NADEM	Time (min)	Conv. <sup>b)</sup> (%)	$M_n$ <sup>b)</sup> (theo)	$M_n$ <sup>c)</sup> (SEC)	$M_w/M_n$ <sup>c)</sup> (SEC)
1		1	33	4100	13000	1.39
2	NIPAM/Men (1/1)	2	61	7200	16000	1.41
3		5	68	8000	17000	1.40
4		10	87	10000	16000	1.43
5		20	94	11000	15000	1.53
6			1	77	9000	12000
7	NIPAM/Tdc (1/1) <sup>d)</sup>	2	95	11000	12000	1.39
8		5	99	12000	15000	1.39
9		10	99	12000	14000	1.49
10		20	99	12000	15000	1.44

<sup>a)</sup> Polymerization with DMPA at room temperature under air.  $[I]_0/[CTA]_0/[M]_0 = 1/1/100$ . <sup>b)</sup> Calculated by <sup>1</sup>H NMR in DMSO-*d*<sub>6</sub>. <sup>c)</sup> Measured by size-exclusion chromatography (SEC) using polystyrene standards in *N,N*-dimethylformamide (DMF, 10 mM LiBr). <sup>d)</sup> Polymerization at approximately 50 °C.

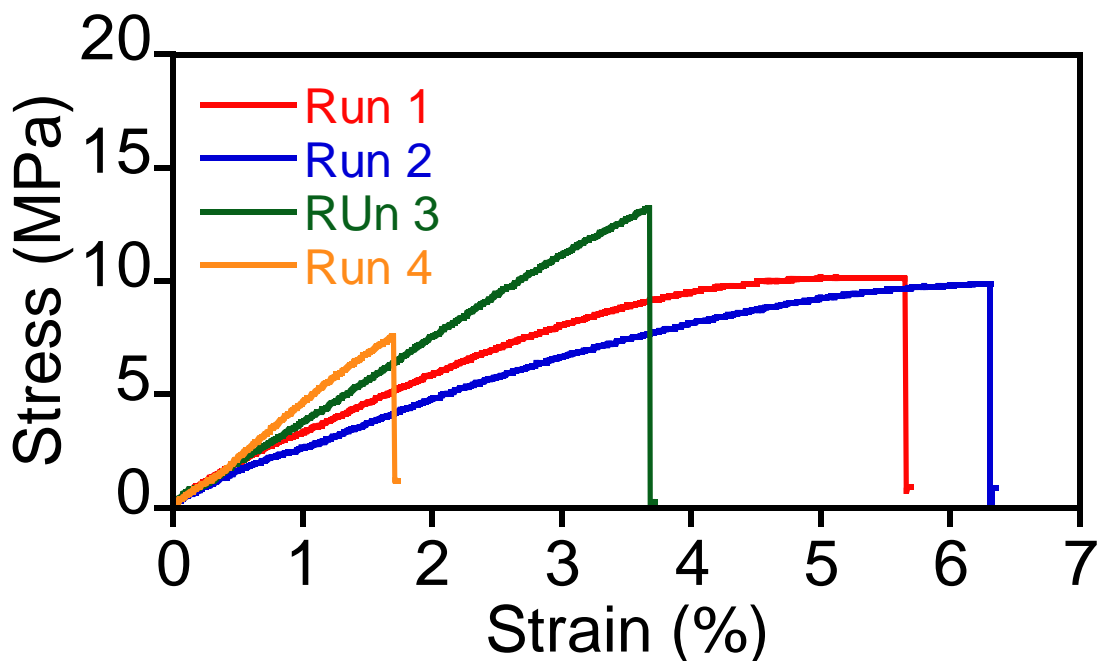
**Table S14.** Photo-induced RAFT polymerization of NADEMs under UV light (LED-UV) <sup>a)</sup>

Run	NADEM	[I] <sub>0</sub> /[CTA] <sub>0</sub> /[M] <sub>0</sub>	Conv. <sup>b)</sup> /Yield <sup>c)</sup> (%)	<i>M<sub>n</sub></i> <sup>b)</sup> (theory)	<i>M<sub>n</sub></i> <sup>d)</sup> (SEC)	<i>M<sub>w</sub></i> / <i>M<sub>n</sub></i> <sup>d)</sup> (SEC)
1		1/1/100	>99/83	11000	17000	1.40
2	NIPAM/Men	1/1/200	>99/80	22000	28000	1.57
3	(1/1)	1/1/500	>99/91	55000	43000	1.71
4		1/1/1000	98/88	110000	52000	2.20
5		1/1/100	94/68	11000	15000	1.43
6	NIPAM/Tdc	1/1/200	94/74	21000	22000	1.69
7	(1/1) <sup>e)</sup>	1/1/500	92/86	52000	37000	1.78
8		1/1/1000	94/78	11000	56000	1.87

<sup>a)</sup> Polymerization with DMPA at room temperature for 2 min under air. [M] = 30 wt%. <sup>b)</sup> Calculated by <sup>1</sup>H NMR in DMSO-*d*<sub>6</sub>. <sup>c)</sup> Diethyl ether-insoluble part. <sup>d)</sup> Measured by size-exclusion chromatography (SEC) using polystyrene standards in *N,N*-dimethylformamide (DMF, 10 mM LiBr). <sup>e)</sup> Polymerization at approximately 50 °C.



**Figure S23.** SEC curves (RI detector, DMF, LiBr) of PNIPAMs obtained by photo-induced RAFT polymerization of NIPAM-based NADEMs at different  $[DMPA]_0/[CTA]_0/[NADEM]_0$  ratios.

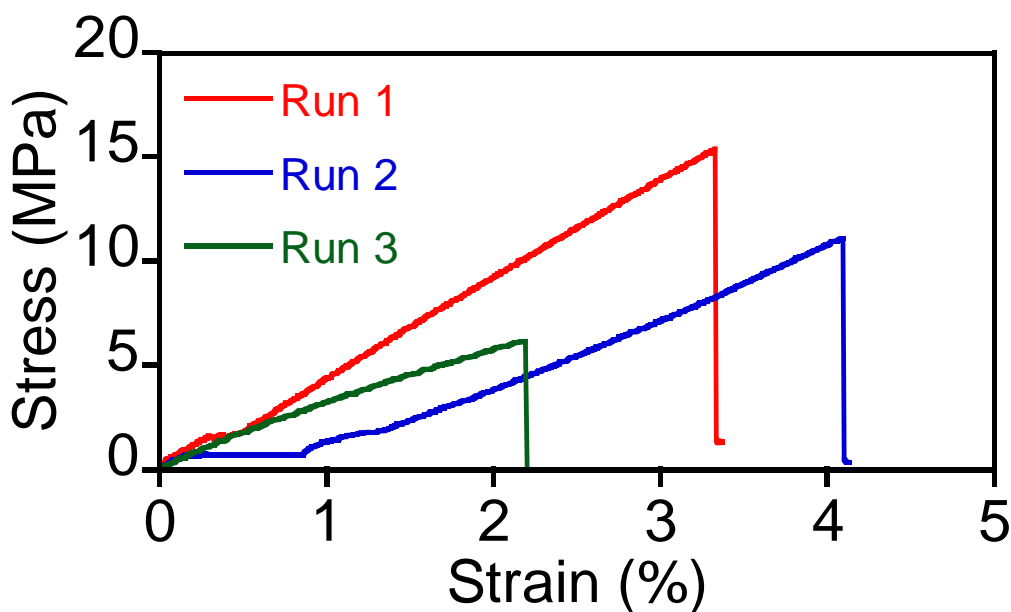


**Figure S24.** Stress–strain curves of polymerized products prepared from NIPAM/Men (3/2).

**Table S15.** Mechanical properties of the polymerized products prepared from NIPAM/Men (3/2) <sup>a)</sup>

Run	Young's modulus <sup>b)</sup> (MPa)	Maximum strength (MPa)	Maximum strain (%)	Modulus of toughness <sup>c)</sup> (MJ/m <sup>3</sup> )
1	399	10.10	5.65	0.39
2	295	9.88	6.30	0.40
3	256	13.20	3.68	0.25
4	370	7.57	1.70	0.07
Average	330	10.19	4.33	0.28

<sup>a)</sup> The sample was prepared independently by photopolymerization of NIPAM/Men (3/2), which was prepared by mixing at 40 °C, with DMPA under LED-UV light (365 nm, 130 mW/cm<sup>2</sup>).  $[I]_0/[M]_0 = 1/100$ . <sup>b)</sup> Calculated from stress at small strain (0.05-0.25). <sup>c)</sup> Estimated by the area under the stress-strain curve until fracture point.

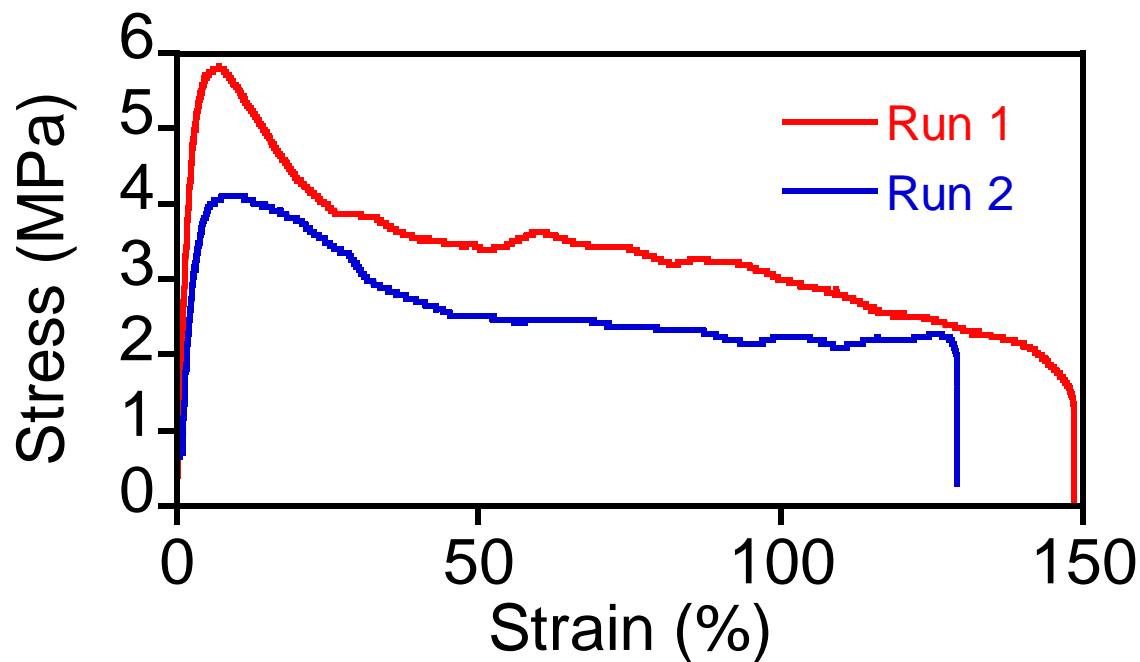


**Figure S25.** Stress–strain curves of polymerized products prepared from NIPAM/Men (2/1).

**Table S16.** Mechanical properties of the polymerized products prepared from NIPAM/Men (2/1) <sup>a)</sup>

Run	Young`s modulus <sup>b)</sup> (MPa)	Maximum strength (MPa)	Maximum strain (%)	Modulus of toughness <sup>c)</sup> (MJ/m <sup>3</sup> )
1	457	15.36	3.36	0.25
2	169	11.06	4.09	0.19
3	366	6.17	2.19	0.07
Average	331	10.86	3.21	0.17

<sup>a)</sup> The sample was prepared independently by photopolymerization of NIPAM/Men (2/1), which was prepared by mixing at 50 °C, with DMPA under LED-UV light (365 nm, 130 mW/cm<sup>2</sup>).  $[I]_0/[M]_0 = 1/100$ . <sup>b)</sup> Calculated from stress at small strain (0.05-0.25). <sup>c)</sup> Estimated by the area under the stress-strain curve until fracture point.

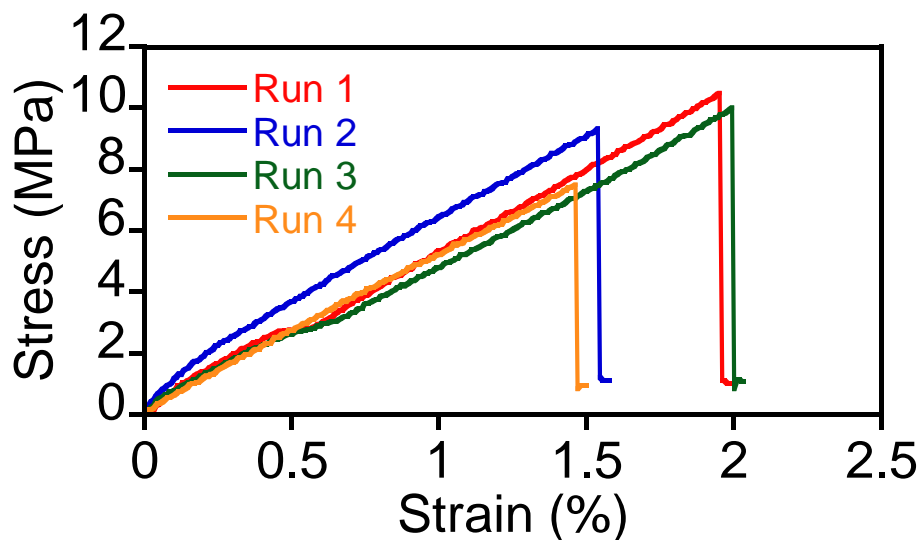


**Figure S26.** Stress–strain curves of polymerized products prepared from NIPAM/Thy (3/2).

**Table S17.** Mechanical properties of the polymerized products prepared from NIPAM/Thy (3/2) <sup>a)</sup>

Run	Young's modulus <sup>b)</sup> (MPa)	Maximum strength (MPa)	Maximum strain (%)	Modulus of toughness <sup>c)</sup> (MJ/m <sup>3</sup> )
1	20.0	5.82	148.70	4.95
2	212	4.05	129.24	3.43
Average	116	4.94	138.97	4.19

<sup>a)</sup> The sample was prepared independently by photopolymerization of NIPAM/Thy (3/2) with DMPA at room temperature under LED-UV light (365 nm, 130 mW/cm<sup>2</sup>).  $[I]_0/[M]_0 = 1/100$ . <sup>b)</sup> Calculated from stress at small strain (0.05-0.25). <sup>c)</sup> Estimated by the area under the stress-strain curve until fracture point.



**Figure S27.** Stress–strain curves of polymerized products prepared from NIPAM/Thy (2/1).

**Table S18.** Mechanical properties of the polymerized products prepared from NIPAM/Thy (2/1) <sup>a)</sup>

Run	Young's modulus <sup>b)</sup> (MPa)	Maximum strength (MPa)	Maximum strain (%)	Modulus of toughness <sup>c)</sup> (MJ/m <sup>3</sup> )
1	627	10.47	1.95	0.10
2	781	9.31	1.54	0.08
3	501	9.98	1.99	0.10
4	533	7.47	1.46	0.06
Average	611	9.31	1.74	0.09

<sup>a)</sup> The sample was prepared independently by photopolymerization of NIPAM/Thy (2/1) with DMPA at room temperature under LED-UV light (365 nm, 130 mW/cm<sup>2</sup>).  $[I]_0/[M]_0 = 1/100$ . <sup>b)</sup> Calculated from stress at small strain (0.05-0.25). <sup>c)</sup> Estimated by the area under the stress-strain curve until fracture point.

NIPAM/Men (1/1)



NIPAM/Thy (1/1)



**Figure S28.** Photographs of the samples prepared by photo-induced free radical polymerization of NIPAM/Men (1/1) and NIPAM/Thy (1/1).

#### References

- (1) van Osch, D. J. G. P.; Dietz, C. H. J. T.; van Spronsen, J.; Kroon, M. C.; Gallucci, F.; Annaland, M. v. S.; Tuinier, R.: A Search for Natural Hydrophobic Deep Eutectic Solvents Based on Natural Components. *ACS Sustainable Chemistry & Engineering* **2019**, *7*, 2933-2942.
- (2) Kanto, R.; Qiao, Y.; Masuko, K.; Furusawa, H.; Yano, S.; Nakabayashi, K.; Mori, H.: Synthesis, Assembled Structures, and DNA Complexation of Thermoresponsive Lysine-Based Zwitterionic and Cationic Block Copolymers. *Langmuir* **2019**, *35*, 4646–4659.